Point Defect Diffusion

K.G. Field^{1,a},

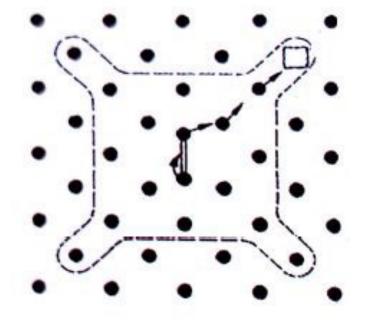
a kgfield@umich.edu

¹University of Michigan



What is the fate of point defects?

1. Annihilation (recombination)



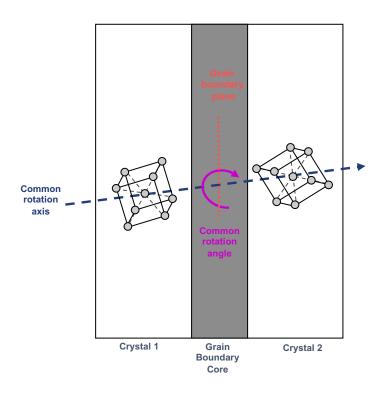
2. Clustering

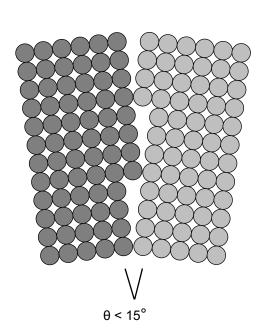
3. Elimination at Sinks

To determine the fate of point defects we need to determine C_{v} and C_{i} at any time during the irradiation, which is tied to their formation and migration!

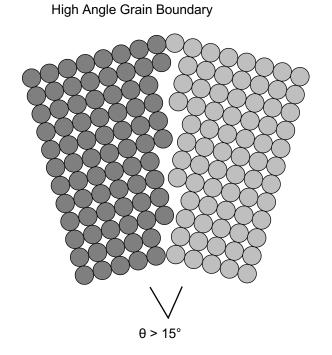


Elimination at Sinks





Low Angle Grain Boundary





Example problem (4.1 in Was) – to make a point

Calculate the concentration of vacancies and interstitials at room temperature for pure Al

$$T = 293 K$$

$$E_f^{v} \approx 0.66 \ eV \qquad S_f^{v} \approx 0.7 k_b$$

$$E_f^{i} \approx 3.2 \ eV \qquad S_f^{i} \approx 8 k_b$$

$$C_i = exp\left(\frac{S_{vib}}{k_b}\right) exp\left(\frac{-E_i}{k_b T}\right) \quad C_v = exp\left(\frac{S_{vib}}{k_b}\right) exp\left(\frac{-E_v}{k_b T}\right)$$



Point defect properties

<u> </u>	Symbol	Unit	A1	Cu	Pt	Mo	W
Interstitials							
Relaxation volume	$V_{\scriptscriptstyle relax}^{i}$	Atomic vol.	1.9	1.4	2.0	1.1	
Formation energy	E_f^i	eV	3.2	2.2	3.5		
Equilibrium concentration at Tm*	$C_i(T_m)$	-	10 ⁻¹⁸	10 ⁻⁷	10 ⁻⁶		
Migration energy	E_m^i	eV	0.12	0.12	0.06		0.054
Vacancies							
Relaxation volume	V_{relax}^{v}	Atomic vol.	0.05	-0.2	-0.4		
Formation energy	E_f^{ν}	eV	0.66	1.27	1.51	3.2	3.8
Formation entropy	S_f^v	k	0.7	2.4			2
Equilibrium concentration at Tm*	$C_{v}(T_{m})$	-	9x10 ⁻⁶	2x10 ⁻⁶			4x10 ⁻⁵
Migration energy	$E_m^{ u}$	eV	0.62	0.8	1.43	1.3	1.8
Activation energy for self diffusion	Q_{vSD}	eV	1.28	2.07	2.9	4.5	5.7
Frenkel pairs	ED						
Formation energy	E_f^{FP}	eV	3.9	3.5	5		



Fick's First Law of Diffusion

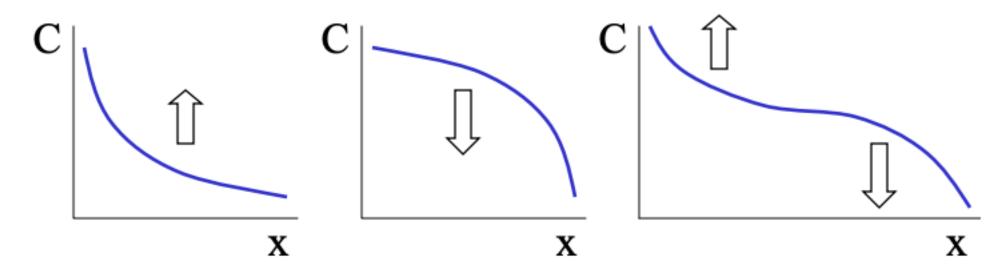
 Relates the flux and the concentration gradient of the diffusing specie:

- D is given in cm²/s or m²/s
- For solids it is between $20-1500^{\circ}$ C, $10-20 < D < 10^{-4}$ cm²/s



Fick's Second Law of Diffusion

 Provides the relationship between the concentration gradient and the rate of range of concentration caused by diffusion at a given point in the system

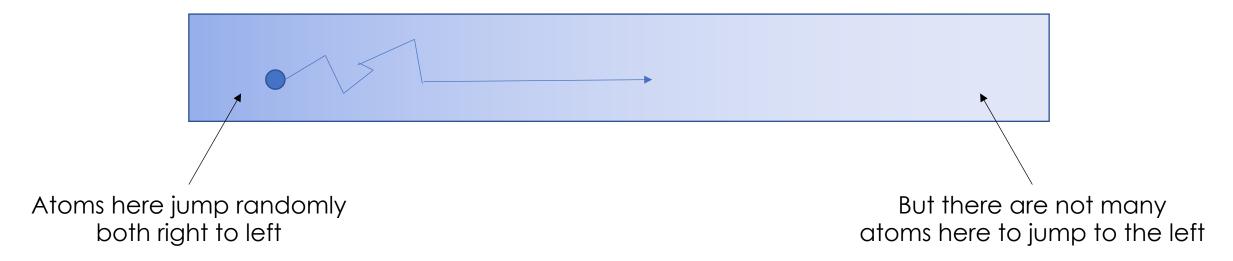




Fick's First Law of Diffusion

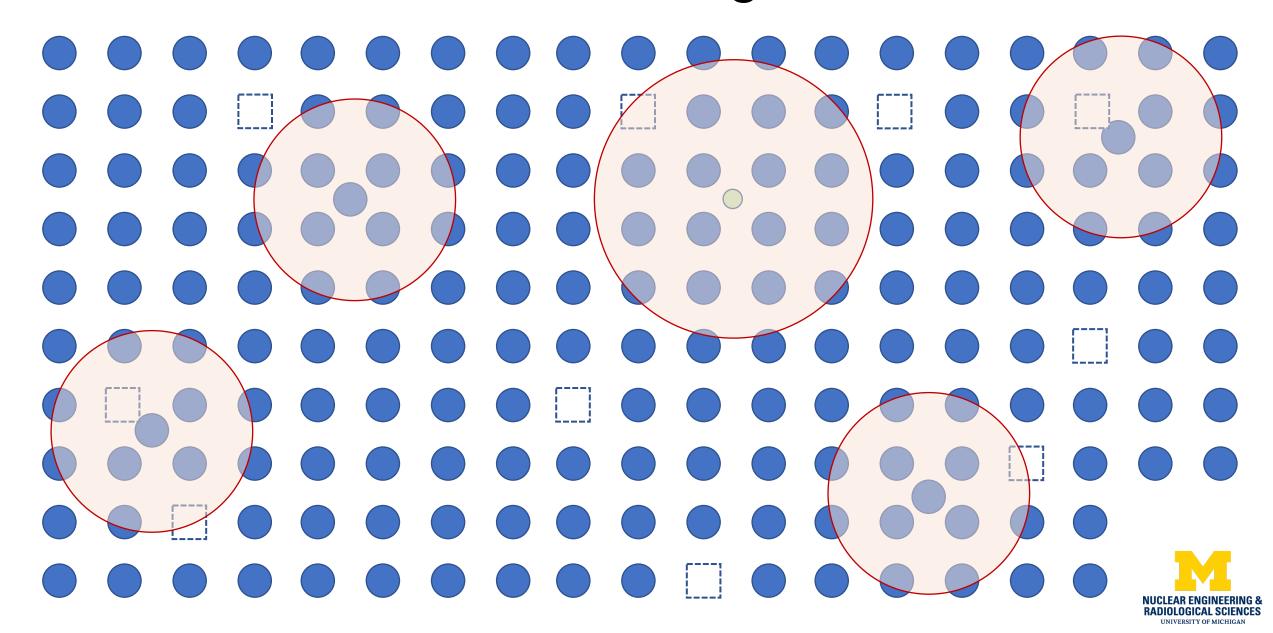
$$J = -D \frac{\partial C}{\partial x}$$

Why do random jumps of atoms result in a net flux of atoms from regions of high concentration towards regions of low concentrations?





Point Defect Migration



How do defect move?

- The defect mobility depends a lot on the defect structure
 - Hence, talking about this is detail last lecture!
- For vacancies, usually a simple jump from one atomic lattice site to another
- For dumbbell interstitials this more complex:

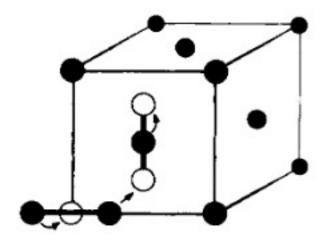


Fig. 4. Migration of the (100)-split interstitial in an fcc lattice.

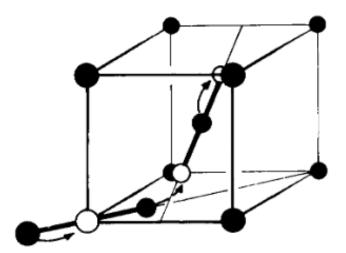
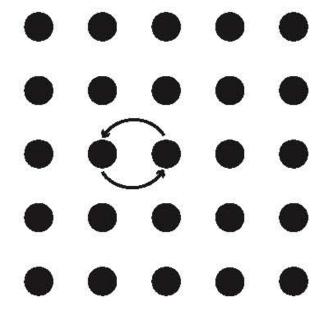


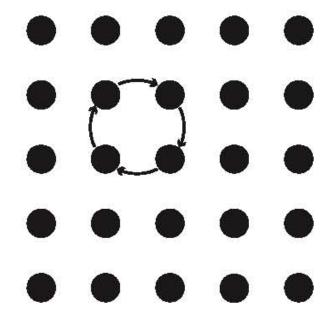
Fig. 9. Migration of the (110)-split interstitial in a bcc lattice.



Exchange Mechanism

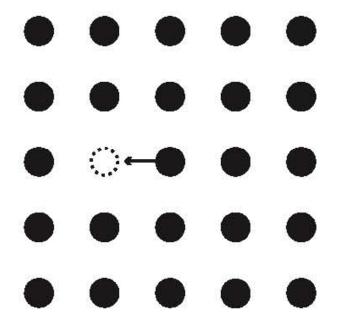


Ring Mechanism

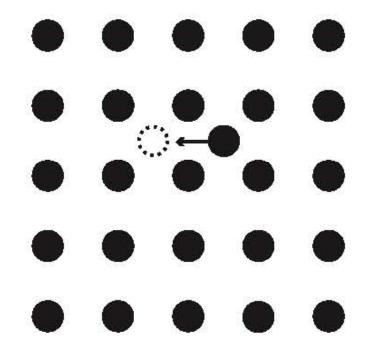




Vacancy Mechanism

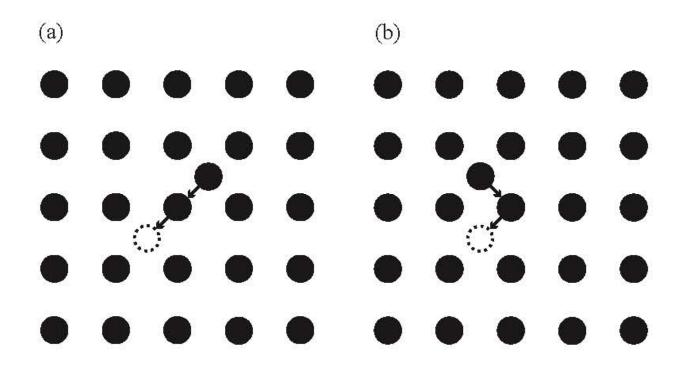


Interstitial Mechanism



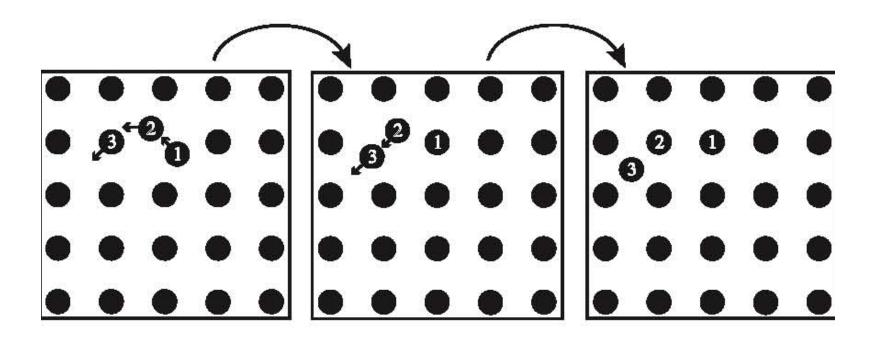


Interstitialcy Mechanism



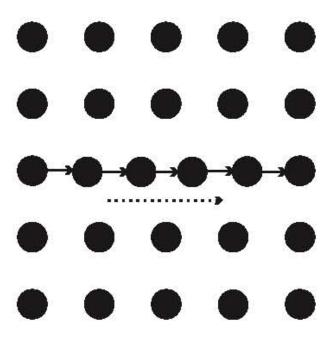


Dumbbell Mechanism





Crowdion mechanism





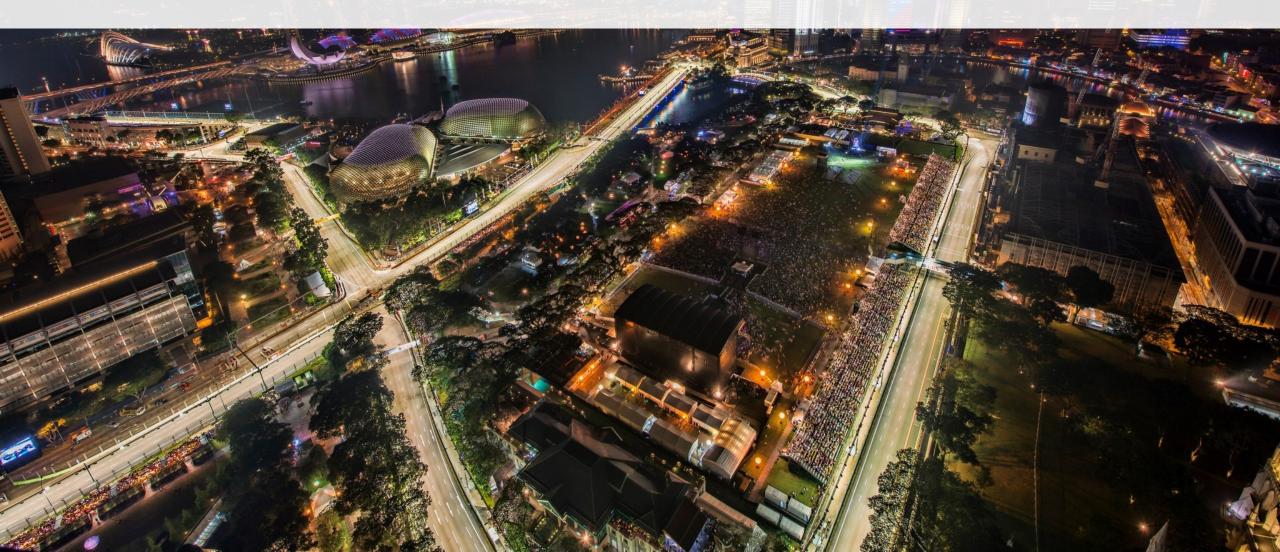
Poll – what mechanism(s) is most dominant

A.Exchange B.Ring C.Vacancy D.Interstitial E.Interstitialcy F.Dumbbell G.Crowdion





The Signapore Grand Prix is F1's first night race. To improve visibility how many light projectors are there around the track?



Microscopic Diffusion

- Assume that the self-diffusion process consists of a completely random walk of defects
- Assume steps of equal length, random directions:

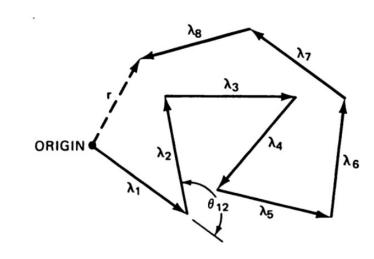


Fig. 7.4 Eight random jumps of equal length λ .



Microscopic Diffusion

$$\bar{r}^2 = n\lambda^2$$

We need to now convert this to a function of time, t. We can do this by considering the frequency of each jump, Γ , and the time allowed for hopping, then we get:

We now need to equate this to the <u>macroscopic</u> diffusion, D. To do this we use Ficks second law of diffusion to describe the probability of finding a spherical shell surrounding an origin:

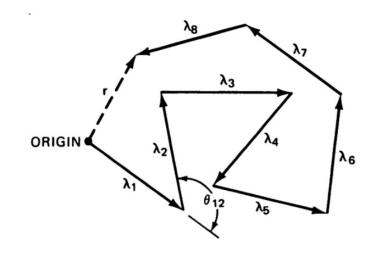


Fig. 7.4 Eight random jumps of equal length λ .



Microscopic Diffusion

Both the macroscopic and microscopic eqautions can be equated together based on both can be defined based on the probability, p_t . To do this, we substitute $p_t(r)$ into:

$$\bar{r}^2 = 4\pi \int_0^\infty r^4 p_t(r) dr$$

And solving, we get simply:

$$\bar{r}^2 = 6Dt$$

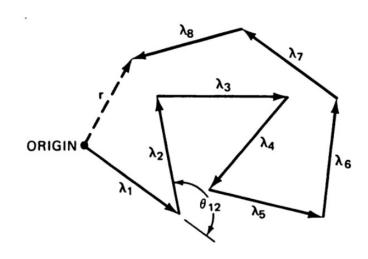


Fig. 7.4 Eight random jumps of equal length λ .



Diffusion accounting for hopping mechanism

Knowing now that:

$$D = \frac{1}{6} \lambda^2 \Gamma$$

We need to determine the jump frequency for a given jump mechanism. This is dependent on the probability a jump site is open, ρ_j , the number of nearest neighbors, z, and the frequency of a given jump type, ω :

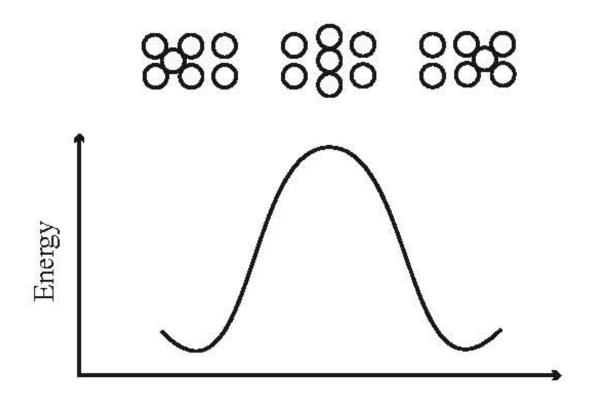


How to determine ω

$$\omega = v \exp\left(\frac{-\Delta G_m}{k_b T}\right)$$

$$\omega = v \exp\left(\frac{-S_m}{k_b}\right) \exp\left(\frac{-\Delta H_m}{k_b T}\right)$$

$$\omega = v \exp\left(\frac{-S_m}{k_b}\right) \exp\left(\frac{-\Delta E_m}{k_b T}\right)$$





Pulling it together to get the diffusion equations:

Diffusion of vacancies:

$$D_{v} = \alpha a^{2} \omega = \alpha a^{2} v \exp\left(\frac{S_{m}^{v}}{k}\right) \exp\left(\frac{-E_{m}^{v}}{kT}\right)$$

Diffusion of atoms by way of vacancies – vacancy self-diffusion:

$$D_a^{\nu} = \alpha a^2 \nu \exp\left(\frac{S_f^{\nu} + S_m^{\nu}}{k}\right) \exp\left(\frac{-E_f^{\nu} - E_m^{\nu}}{kT}\right).$$

Diffusion of interstitials:

$$D_i = \alpha a^2 v \exp\left(\frac{S_m^i}{k}\right) \exp\left(\frac{-E_m^i}{kT}\right).$$

Diffusion of atoms by way of interstitials – interstitial self-diffusion:

$$D_a^i = \alpha a^2 v \exp\left(\frac{S_f^i + S_m^i}{k}\right) \exp\left(\frac{-E_f^i + -E_m^i}{kT}\right).$$



Or, more simply:

We can use an Arrhenius relationship:

$$D = D_0 exp\left(\frac{-Q}{k_b T}\right)$$

Where D_o and Q are given but incorporate the discussed factors:

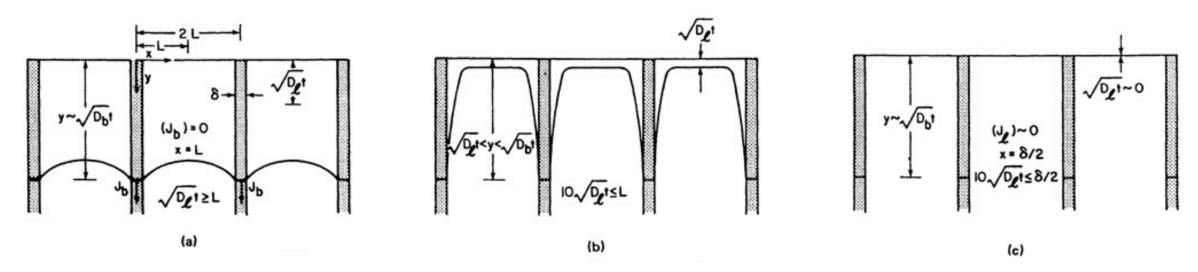
Mechanism	D _o	Q
Vacancy Diffusion (D_v)	$\alpha a_o^2 vexp\left(\frac{S_m^v}{k_b}\right)$	E_m^v
Vacancy Self Diffusion (D_a^{ν})	$\alpha a_o^2 v exp\left(\frac{S_f^v + S_m^v}{k_b}\right)$	$E_f^v + E_m^v$



D



Diffusion along high-diffusivity paths:



Type A: The diffusion front in the bulk and in the boundary advanced at the same speed

Type B: The diffusion in the grain boundary is faster than in the bulk

Type C: The diffusion in the bulk is negligible and grain boundary diffusion is only active



Point defect properties

<u> </u>	Symbol	Unit	A1	Cu	Pt	Mo	W
Interstitials							
Relaxation volume	$V_{\scriptscriptstyle relax}^{i}$	Atomic vol.	1.9	1.4	2.0	1.1	
Formation energy	E_f^i	eV	3.2	2.2	3.5		
Equilibrium concentration at Tm*	$C_i(T_m)$	-	10 ⁻¹⁸	10 ⁻⁷	10 ⁻⁶		
Migration energy	E_m^i	eV	0.12	0.12	0.06		0.054
Vacancies							
Relaxation volume	V_{relax}^{v}	Atomic vol.	0.05	-0.2	-0.4		
Formation energy	E_f^{ν}	eV	0.66	1.27	1.51	3.2	3.8
Formation entropy	S_f^v	k	0.7	2.4			2
Equilibrium concentration at Tm*	$C_{v}(T_{m})$	-	9x10 ⁻⁶	2x10 ⁻⁶			4x10 ⁻⁵
Migration energy	$E_m^{ u}$	eV	0.62	0.8	1.43	1.3	1.8
Activation energy for self diffusion	Q_{vSD}	eV	1.28	2.07	2.9	4.5	5.7
Frenkel pairs	ED						
Formation energy	E_f^{FP}	eV	3.9	3.5	5		

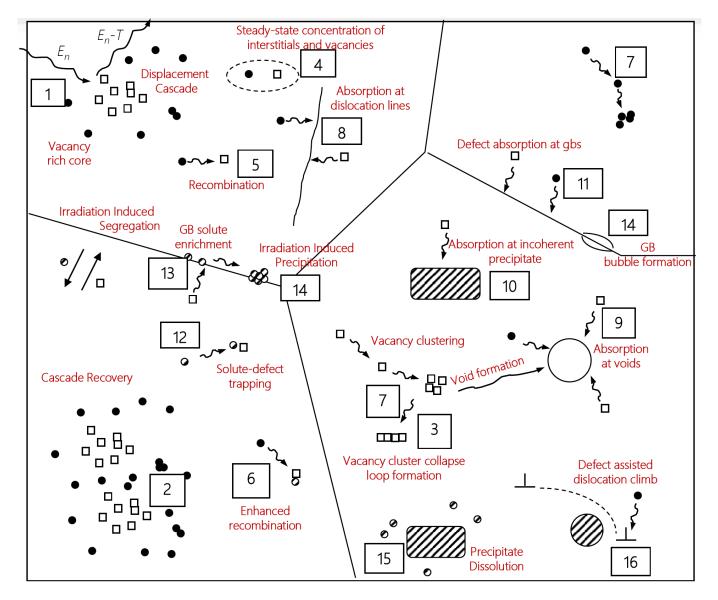


Point Defect Diffusion: Comparison

- Comparsion of diffusion
 - $t = 10^6 s (11 days)$
 - $E_m^f = 1 \ eV$, $E_m^i = 0.2 \ eV$

T (°C)	$D_V(m^2/s)$	$X_V = \sqrt{D_V \tau}$	$D_i(m^2/s)$	$X_i = \sqrt{D_i \tau}$
0	2×10^{-21}	0.45nm	1.5×10^{-6}	1cm
100	2×10^{-16}	150nm	1.5×10^{-5}	4cm
200	1.7×10^{-13}	4µm	5.5×10^{-5}	7.5cm
300	1.2×10^{-11}	35µm	1.3×10^{-4}	11cm
400	2.5×10^{-10}	0.15mm	2.4×10^{-4}	15cm
500	2.3×10^{-9}	4mm	3.7×10^{-4}	19cm

Radiation Effects at the Grain Scale



Goal: Determine the kinetics of microstructure evolution under irradiation



